How to Increase the h-BN Crystallinity of Microfilms and Self-Standing Nanosheets: A Review of the Different Strategies Using the PDCs Route

Sheng Yuan 1,2, Catherine Journet 1, Sébastien Linas 1, Vincent Garnier 2, Philippe Steyer 2, Stéphane Benayoun 3, Arnaud Brioude 1 and Bérangère Toury 1,*

1 Laboratoire des Multimatériaux et Interfaces, UMR CNRS 5615, Université de Lyon, LYON1, F-69622 Villeurbanne, France; sheng.yuan@insa-lyon.fr (S.Y.); catherine.journet@univ-lyon1.fr (C.J.); sebastien.linas@univ-lyon1.fr (S.L.); arnaud.brioude@univ-lyon1.fr (A.B.)
2 Matériaux Ingénierie et Science, UMR CNRS 5510, INSA de Lyon, Université de Lyon, F-69621 Villeurbanne, France; vincent.garnier@insa-lyon.fr (V.G.); philippe.steyer@insa-lyon.fr (P.S.)
3 Laboratoire de Tribologie et Dynamique des Systèmes, Ecole Centrale de Lyon, F-69130 Ecully, France; stephane.benayoun@ec-lyon.fr
* Correspondence: toury@univ-lyon1.fr; Tel.: +33-4-7243-3612

Academic Editors: Umit B. Demirci, Philippe Miele and Pascal G. Yot
Received: 7 April 2016; Accepted: 3 May 2016; Published: 13 May 2016

Abstract: Hexagonal boron nitride (h-BN) is a well-known material whose use is almost restricted to lubricating applications in domains ranging from metallurgy to cosmetics. However, h-BN displays many other interesting properties, opening new perspectives for other engineering applications, such as as a solid lubricant in aeronautics, as the perfect substrate to graphene for electronic devices, etc. However, all these promising developments require tailored h-BN shapes displaying a high level of crystallization, ensuring its properties for the long term. Here, we developed three strategies, all associated with the Polymer Derived Ceramics (PDCs) route, to prepare highly crystallized supported thick coatings and self-standing nanosheets. The first strategy concerns the innovative implementation of a Rapid Thermal Annealing to prepare micrometric h-BN coatings on thermal sensitive substrates. Compared to conventional treatment the crystallization of h-BN has successfully lowered to about 300 °C. The second strategy consists of an additivation of the used polymer precursor. Effect of lithium nitride as a crystallization promoter was investigated lowering the onset crystallization temperature from 1400 °C (traditionally) to 1000 °C. This novel synthetic route allows preparing self-standing highly crystallized h-BN nanolayers. Finally, the third strategy is based on a unique combination of the PDCs route with Spark Plasma Sintering to profit of both approaches. This original method leads to large and well-crystallized flakes available for a subsequent exfoliation.

Keywords: h-BN; PDCs; 2D nanolayers; coatings; nanosheets

1. Introduction

Hexagonal boron nitride (h-BN) is a famous non oxide ceramic known and appreciated for its numerous interesting properties, such as a high thermal conductivity, an excellent thermal chock resistance, a high resistance against oxidation (850 °C under air), a good chemical inertness [1,2], etc. Based on this non exhaustive list of important properties, it is easy to understand the key role of h-BN for real or potential applications. Actually, h-BN can be found many fields ranging from cosmetics to metallurgy passing by aeronautics or battery [1].

Another very interesting specificity of h-BN is linked to its structural similarity to graphite doing of themselves twin materials [3]. Actually, the h-BN progression is always directly linked to graphite counterparts. Examples are numerous, such as the preparation of boron nitride fibers in replacement of
the carbon ones to be used at high temperature under air [4–8] the synthesis of boron nitride nanotubes after the discovery of the CNTs in the early 1990s [9–11], the preparation of analogue boron nitride fullerene/nanocage somewhat latter [12,13] and more recently the myriad of studies to get boron nitride monolayers within the explosion of graphene [3,14,15]. All these examples show that the shape given to the ceramic is at least as important as the material itself, meaning that the shaping is essential to ensure potential applications.

The production of commercial h-BN powders is now completely mastered from an oxygen-containing boron compound reacting with a nitrogen-containing source [1,16–18]. The use of such powders is clearly convenient to provide sintered pieces but really restrains the possibility to reach others specific shapes (fibers, foams, coatings, etc.) In the latter case, a versatile alternative has to be found. The Polymer Derived ceramics (PDCs), developed in the late 1960s by Chantrell and Popper [19] for a non-oxide system is undoubtedly a good choice [20]. This route consists in the synthesis of very pure preceramic polymer from tailored molecular precursor. The preceramic polymer (liquid, soluble or fusible) can be then easily shaped into the convenient shape by means of dip- spin-coating, casting, melt-spinning [21], etc. Followed by an appropriate thermal treatment. The preceramic polymer body is then converted into hexagonal boron nitride while maintaining the desired shape. Obviously, the selection of the starting precursor is essential and should follow guidelines. Among all available precursors [22–24], borazine (B\(_3\)N\(_3\)H\(_6\)) or polyborazilene (PBN) (\(-(B\(_3\)N\(_3\)H\(_4\))\(_n\)-\) [25–29], the latter being directly derived from the polycondensation of the former, are very attractive because they are prepared through a reproducible synthesis, whitout any contaminant within compounds and a perfect B/N stoichiometry... PBN, which presents the advantage of a lower volatility and a better ceramic yield, is always preferred to borazine [30].

For half a decade, our group focused attention on thick h-BN coating deposited on metallic substrate especially on titanium to get self-lubricating devices available in aeronautics industry [31–33]. Actually, thanks to its lamellar structure combined to its important oxidation resistance even at high temperature under air, h-BN is one of the best candidates for protecting metal components in engineering. However, to give a high protectiveness, the ceramic may reach a high level of crystallization, which becomes a key parameter to manage. Traditionally, thin h-BN coatings are prepared through conventional sputtering [34], PLD [35,36], CVD and derivatives [37–42], these latter being the most studied [43]. Moreover, on top of the heavy equipment needed [44], coatings often display a low crystallinity, oxygen contamination or a non stoichiometric B/N ratio [43]. In this context, the PDCs route appears as a relevant alternative to get advanced coatings. The use of a liquid phase allows a simple shaping by means of dip- or spin-coating able to control the thickness [45]. A review from 2011 [46] reports studies on the synthesis of h-BN coatings by preceramic polymers. Among them, we can cite the dibromoborane-dimethyl sulfide [47], the tris(alkylamino)borane [48,49], the alkylaminoborazine and derivatives [30,50], the borazine [30] and the PBN [30–33,45,50–53]. Hence, there are many precursor sources, but, the best results, in terms of homogeneity and purity, are systematically obtained with PBN. Actually, by controlling the polycondensation step, PBN can be prepared as a liquid polymer easy to handle and to shape. Besides, an appropriate thermal treatment allows easily converting the green preceramic coating into a contaminant-free crystallized h-BN one, the ceramic crystallization remaining a key parameter to get efficient coated devices.

More recently, motivated by the veritable craze for graphene (G), the current 2D superstar material, we have been witnessing to an increasing demand in BN nanolayers to be used as graphene substrate to keep advantages of its remarkable transport properties [54]. Actually, the common use of silica as insulating substrate to get a handled device remains insufficient to prepare efficient systems, its surface imperfections significantly affects the supported graphene carrier mobility. In that context, many studies claim the potential of h-BN as suitable dielectric substrate for graphene [55–57]. Actually, the perfect lattice matching of h-BN with graphene [58] coupled with the fact that h-BN has an atomically flat and dangling bond-free surface, will ensure no charge traps at the G/h-BN interface and consequently will increase of graphene’s carrier mobility [59,60]. These constraints explained
efforts to target uniform thickness, large domain size and high crystallinity. From these guidelines, two options can be distinguished, either a growth of h-BN by CVD or an exfoliation of large single crystals. Today, many studies are devoted to the first way, exploring a variety of transition metals as substrate, such as Ni and Fe films, Pt foil, Cu-Ni alloys, [61–72], the most common remaining Cu foils [73–75]. Even if results are more and more relevant, with the increasing size of domains, this route needs heavy equipment and reproducibility is strongly dependent on the used apparatus, which really limits its development. Besides, the production is limited. Keeping these issues in mind, the second way, involving exfoliation of single crystals, is relevant if an accessible source of pure and highly crystallized crystals becomes available [76]. It is well-known that the group of Watanabe at the National Institute for Materials Science (NIMS) [77,78] can prepare this kind of high quality single crystals using the High Pressure High Temperature (HPHT) process, but the whole procedure runs through severe production conditions and long treatment time [76] making its widespread restricted. Commercial sources [17,18] are more reachable but the quality remains characterized by a high level of defects and relatively small crystalline areas [76]. In that latter case, synthetic material can suffer of a lack of crystallization, often linked to the synthetic process used.

In this review, we focused our attention on three main strategies developed in the group in order to increase the h-BN crystallization for supported thick coatings and self-standing nanosheets prepared through the PDCs route. Our approach is based either on the process, or on the chemistry of reactants (sometimes on both). If the easiest way to enhance crystallization consists in a simple increase of the final treatment temperature, this is not systematically allowed, for apparatus limitations reason, due to a cost restrictions or due to substrate specificities (thermal sensitivity for example). Alternatives have, then, to be found. Our first studies are focused on the ceramization process. Hence, we explored the possibility of preparing h-BN coatings on metallic substrates using an innovative IR irradiation annealing process. Since the metallic substrate reflects IR radiation, only the outer preceramic coating is irradiated, preserving the subjacent substrate integrity. The second strategy is directly linked to the chemistry, with the additivation of the polymeric precursor with a crystallization promoter, acting as a catalyst to favor the crystallization occurring during the ceramization step. Finally, to go further, we implemented a third strategy combining the additivation and the use of a particular sintering process, which is the Spark Plasma Sintering (SPS).

2. First strategy: Rapid Thermal Annealing (RTA)

As mentioned above, performances of h-BN protective coating are closely correlated to its crystallization state which traditionally requires an appropriate thermal treatment of the green material to favor its ceramization and crystallization at a temperature ranging from 1600 to 1800 °C under an inert atmosphere. Considering these drastic conditions, only ceramic substrates can be used, metals thermally sensitive or susceptible to phase transitions. However, for specific applications, metallic substrates can be required (e.g., titanium based alloys for the aeronautic industry), that is why we propose an alternative annealing method using infrared (IR) irradiation with either a simple halogen lamp or an advanced Rapid Thermal Annealing (RTA) (Figure 1) furnace instead of a conventional resistive one. In this configuration, the IR radiation is absorbed by the green material to initiate the polymer-to-ceramic conversion, while the metallic substrate reflects the highest part of the irradiation, meaning that only the pre-ceramic coating is heated during the annealing preserving the sustrate.

![Figure 1. Rapid Thermal Annealing system.](image-url)
2.1. Influence of the Annealing Temperature

In order to study the influence of the annealing temperature vs the h-BN crystallization, in the first phase, we prepare 5 samples, a titanium substrate (2 × 10 × 50 mm$^3$) dip-coated in liquid pure PBN then heat treated under a halogen lamp heated at 800, 900, 1000, 1100 and 1200 °C for 1h in a gloves box, leading to samples TiBN800 to TiBN1200, respectively. The so-obtained coatings are homogenous and recovering according to the microscopic observations. A representative example of the surface is shown in Figure 2.

Figure 2. SEM image of sample TiBN1200, representative of the homogeneity of the top surface.

AFM measurement performed on TiBN1200 shows a flat surface within large area and gives a root-mean-square roughness (RMS) of 20 nm [33]. The thickness of the coating can be adjusted by the dip-coating parameters and layer number. For instance, after optimization, we obtained a defect-free 16 µm-thick coating. Such a result is of prime interest, since the ensuing coating is thicker than most of BN coatings obtained either by PDCs [79–81], CVD [62] or PVD [82]. Figure 3 shows IR spectra of pure PBN (red curve) compared to TiBN1200 (black curve). Both spectra show the loss of the two signals assigned to B-H and N-H vibrations, respectively at 2510 et 3450 cm$^{-1}$, evidencing the ceramization of PBN during annealing. Furthermore, the presence of both expected signals for h-BN at 1378 and at 790 cm$^{-1}$ respectively characteristic of B-N stretching and B-N-B bending vibration modes, ensure the preparation of the expected ceramic.

Figure 3. FTIR spectra recorded on pure PBN (red) and TiBN1200 (black).
The conversion of PBN into h-BN from 800 to 1200 °C was also evidenced by Raman analysis. Actually, Figure 4 shows that the broad E\textsubscript{2g} signal characteristic of amorphous preceramic becomes thinner and thinner revealing the upcoming hexagonal structure.

![Raman spectra recorded on samples TiBN800 (black) to TiBN1200 (green).](image)

The same analyses are also carried out by XRD on all the samples, driving to the same conclusion. In general, h-BN crystallite displays pellet-like structure with the sheet extension parameters, L\textsubscript{a}, much higher than the parallel layer’s average stack height, L\textsubscript{c}. In our case, both values can be estimated by the means of Raman and XRD, respectively. Calculation of L\textsubscript{c} value is based on the well-known Sherrer’s equation considering the (002) peak. Figure 5 displays the change in L\textsubscript{c} as a function of the applied annealing temperature. It appears that L\textsubscript{c} values increase from 1.42 to 1.71 nm as the thermal treatment temperature increases from 800 to 1200 °C. Moreover, Nemanich et al. reported a correlation between width and shift peak of E\textsubscript{2g} and the average crystallites size L\textsubscript{a} of h-BN [83]. The crystallites size, L\textsubscript{a}, calculated using the latter relation indicates (Figure 5) the same tendency as the L\textsubscript{a} increases from 1nm to around 4.7 nm, with increasing temperature.

![Graphs showing the evolution of L\textsubscript{c} (calculated from Sherrer’s equation) (blue) and L\textsubscript{a} (calculated from Nemanich’ correlation) (black) as function of the annealing temperature.](image)
This relatively small crystallite size is proved by direct HR-TEM observations showing the hexagonal structure and crystallite sizes around 5 nm [33]. Besides, we have shown that the ceramic is stable towards air. Actually, XPS chemical analyses, performed on two samples (one just after its synthesis, the other one after more than 2 months under air), reveals no further oxidation. The chemical composition (B/N) remains close to the stoichiometry [33].

In conclusion, it is interesting to notice that annealing at 1200 °C using IR irradiation may give rise to crystallites characterized by almost the same crystallite size as that obtained via heat treatment in a resistive furnace at 1500 °C, leading to a gain of 300 °C [8]. In addition, it has been proven that this alternative annealing allows decreasing the onset of crystallization temperature down to 900 °C using PBN as precursor.

2.2. Influence of Annealing Process and Atmosphere (RTA)

To reach a high annealing temperature while avoiding any overheating of the substrate, we used an advanced RTA furnace instead of the simple halogen lamp. The heating program is adapted to that quick process, i.e., a rapid temperature increasing (8 °C/s) up to the plateau temperature (Tp = 900 °C) and the deliverance of 6 or 9 flashes of 5 s at 1350 °C under N2 or Ar. Each flash is performed after the temperature reaches again the Tp. First, one can mention that the annealing atmosphere has no visible influence on the crystallization state of the final coating, since TiBN1350-N2 and TiBN1350-Ar present almost the same XRD and Raman signature of the surface. Second, the benefit of the higher temperature (1350 °C) compared to the previous one (1200 °C) is evidenced by the XRD analysis. Actually, according to the XRD data (Table 1), the interlayer parameter \( d \) was calculated thanks to the Bragg’s law is given to be 3.47 Å vs. 3.60 Å for TiBN1350-9f and TiBN1200, respectively, which is much closer to the theoretical value given to 3.33 Å [33]. In addition, Table 1 also shows that an increase in the number of flashes allows to get a ceramic with a \( L_c \) reaching 3 nm.

<table>
<thead>
<tr>
<th>Sample</th>
<th>( \theta_{002} ) (°)</th>
<th>( d_{002} ) (Å) (^1)</th>
<th>FWHM(002)</th>
<th>( L_c ) (nm)</th>
</tr>
</thead>
<tbody>
<tr>
<td>TiBN1200</td>
<td>24.5</td>
<td>3.60</td>
<td>4.83</td>
<td>1.7</td>
</tr>
<tr>
<td>TiBN1350-9f</td>
<td>25.8</td>
<td>3.44</td>
<td>2.9</td>
<td>3.0</td>
</tr>
<tr>
<td>TiBN1350-6f</td>
<td>25.3</td>
<td>3.52</td>
<td>2.8</td>
<td>2.9</td>
</tr>
</tbody>
</table>

\(^1\) interlayer parameter calculated thanks to the Bragg’s law.

In summary, the whole study tends to show the real potential of an IR annealing to perform crystallized boron nitride, displaying a good chemical stability, at quite low temperature with an onset of crystallization as low as 900 °C. However, the crystallization should even be improved and other advanced strategies should be studied and applied.

3. Second Strategy: Li\(_3\)N as Crystallization Promoter

Besides the process that can be adjusted to enhance the ceramic crystallization conditions, another tactic may consist in playing with the chemistry of reactants involved during the synthesis. Actually, there are intrinsic relationships existing between properties of both precursors (or solution) and the resulting final material. Hence, either modifying the chemical nature of the used precursor or additivating it with a crystallization promoter would play a key role on the final crystallinity of the ceramic. In that way, as already mentioned in the introduction, the used of PBN as preceramic precursor is particularly relevant [30,50,51,84] since it is prepared through pure borazine that initially displays the expected targeted hexagonal arrangement [85]. Moreover, since the polymer is obtained without any solvent addition, only hydrogen is expected to be lost [25,86–88] and no contaminant is present, whose presence may slow down the crystallization process. Some studies report the addition of calcium carbonate [1,16,77,89] or lithium nitride to increase the final h-BN crystallization.
However, Li₃N is more classically used for conversion of h-BN to c-BN at relatively low temperature and pressure [90–94]. Based on these relevant results, we decided to add lithium nitride (Li₃N) in pure PBN in order to lower the onset crystallization temperature [95].

3.1. Evidence of Li₃N Effect

First to highlight the key role of this additive in crystallization enhancement of the final ceramic, we performed Thermo Gravimetric Analyses (TGA) on two reference samples; pure PBN and PBN mixed with Li₃N micro powders (5wt. %), respectively named PBN and PBN-Li₃N (Figure 6).

Comparison of both curves shows three main differences. First, a lower weight loss for PBN-Li₃N sample at 600 °C: 13% vs. 17% for PBN sample is observed, the difference (Δm₁) indicating the additive preservation. The second difference corresponds to a higher weight loss for the additivated sample between 600 and 1000 °C interpreted as the removal of the additive or a product derived from the latter stage. Based on previous articles, we can assume that at this temperature range, a reaction occurs between Li₃N and the former BN to get Li₃BN₂ [96,97]. This specie can exist through two different structures α-Li₃BN₂ and β-Li₃BN₂ melting at 860 °C and 920 °C, respectively, so likely to be eliminated under the N₂ flow. Finally, the last divergence comes from the behavior of both products up to 1200 °C. Actually, the TGA curve recorded on the BN derived from the PBN-Li₃N sample stays stable up to 1400 °C, meaning that the sample is not changing. Besides, the TGA curve from the BN produced from the pure PBN gains mass (Δm₂) and this non-expected behavior can be attributed to oxidation (with residual air in the chamber) [53] meaning that the sample is not stable and sensitive to oxidation probably because of a worse crystallization [98].

Further structural characterization by means of Raman spectroscopy and X-ray diffraction are performed on both TGA residues. First, both Raman spectra (Figure 7) exhibit a characteristic signature of hexagonal boron nitride, with a broad signal around 1367 cm⁻¹ typical of the E₂g mode peak of h-BN [83]. The first difference comes from the FWHM measured to be 52 cm⁻¹ vs. 38 cm⁻¹ and the Lₐ calculated [83] to be 8.6 nm vs. 38 nm respectively for the pure and additivated samples, meaning a better crystallization of the latter sample. The second difference comes from an additional signal within the PBN-Li₃N derivative sample spectrum at 810 cm⁻¹ and assigned to boron oxide [99] confirming the compound oxidation as previously suggested by TGA.
XRD patterns, proposed on Figure 8, also present the signature of hexagonal boron nitride with a main signal at around 26.8° corresponding to the (002) diffraction peak, according to the JCPDS file 009-0012. Moreover, examination of values reported on the Table 2 and corresponding to the main (observed or calculated) [33] XRD parameters clearly shows that the sample prepared with the pure PBN displays a lower crystallization compared to this obtained from PBN-Li3N.

![Raman spectra recorded on both TGA residues derived PBN (red) and PBN-Li3N (black).](image1.png)

**Figure 7.** Raman spectra recorded on both TGA residues derived PBN (red) and PBN-Li3N (black).

<table>
<thead>
<tr>
<th>Sample</th>
<th>d_{002} (Å)</th>
<th>θ_{002} (°)</th>
<th>FWHM_{002}</th>
<th>θ_{10} (°)</th>
<th>FWHM_{10}</th>
<th>L_c (nm)</th>
<th>L_a (nm)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Commercial h-BN</td>
<td>3.31</td>
<td>26.9</td>
<td>0.35</td>
<td>41.7</td>
<td>-</td>
<td>-\textsuperscript{1}</td>
<td>-\textsuperscript{1}</td>
</tr>
<tr>
<td>Li3N-PBN</td>
<td>3.33</td>
<td>26.7</td>
<td>0.92</td>
<td>42.0</td>
<td>1.0</td>
<td>37.8</td>
<td>38.0</td>
</tr>
<tr>
<td>PBN</td>
<td>3.54</td>
<td>25.1</td>
<td>3.61</td>
<td>42.6</td>
<td>2.2</td>
<td>2.3</td>
<td>8.6</td>
</tr>
</tbody>
</table>

\textsuperscript{1} Since Scherrer’s equation is limited for the range of crystallite sizes varying from 1 to 100 nm, not calculable here.

The fact that this latter XRD pattern displays a shoulder towards the low 2θ values (~25°), meaning a dispersion in the crystallites size, can be related to its very short stay at 1400 °C. By tailoring the ceramization parameters one can expect to enhance even more the crystallization state.

![XRD patterns recorded on both TGA residues derived PBN (blue) and PBN-Li3N (red).](image2.png)

**Figure 8.** XRD patterns recorded on both TGA residues derived PBN (blue) and PBN-Li3N (red).
3.2. Influence of the Annealing Temperature on h-BN Crystallization

In order to understand the chemical and structural mechanism occurring with the ceramic derived from the additivated precursor, a series of BN samples incorporating Li$_3$N (5wt.%) and annealed at 600, 800, 1000, 1200 and 1400 °C (denoted, respectively LiBN01 to LiBN05) is prepared. Diffractogramms recorded on each sample are gathered in Figure 9. LiBN01 sample is completely amorphous, in good accordance with the TGA curve that shows that the catalytic effect is not expected at this lowest temperature. Regarding LiBN02, we evidenced a signature of turbostratic BN coupled with other signals attributed here to the Li$_3$BN$_2$. Our assumption is again confirmed with the formation, between 800 and 1000 °C of Li$_3$BN$_2$ from a reaction between Li$_3$N and the former BN. From 1000 to 1400 °C, differences within the XRD patterns remain marginal, with refining signals, meaning a decrease in the measured FWHM and calculated d$_{002}$ values obtained on the (002) diffraction peak as attested in Figure 10. In conclusion, the beneficial effect of the addition of Li$_3$N within the PBN is clearly visible from 1000 °C and even more accentuated at 1200 and 1400 °C.

![Figure 9. XRD patterns recorded on samples LiBN01 (black), LiBN02 (red), LiBN03 (blue), LiBN04 (magenta) and LiBN05 (green).](image)

![Figure 10. Influence of the annealing temperature on FWHM (black) and d$_{002}$ (blue).](image)

The proposed crystallization mechanism is based on previous studies reported by Bezrukov [100] and other groups [97,101,102]. At around 600–700 °C, Li$_3$BN$_2$ formed by reaction between Li$_3$N and preceramic BN, melts and infiltrates amorphous BN and dissolves it, leading to highly crystallized hexagonal boron nitride.
The main interest in this additivation is to drastically decrease the crystallization temperature from traditionally, at least 1500 °C [25], to 1000–1200 °C. To our knowledge, we are the first to demonstrate the additive activity of Li$_3$N when adding in a preceramic polymer and the heat treatment of that mixture.

3.3. Thick h-BN Synthesis

From this important result we decided to combine the use of an additivated polymer to a RTA thermal annealing to get crystallized h-BN coating over titanium substrate while preserving the latter integrity and saving time [31].

In that way, pure PBN is mixed with micro sized Li$_3$N powders, in 1, 3 or 5wt. % and stirred for 30 min in a gloves box. Still under argon, each solution is deposited on a titanium substrate, previously cleaned with ethanol. Coated samples are then kept at 200 °C for 1 h to avoid further important polymer volatilization. Finally, samples are placed in the RTA furnace and heated at 1200 °C under N$_2$ underwent 9 flashes following a program described above. The 3 resulting samples are named TiBN1, TiBN3 and TiBN5. The naked substrate undergoing the same annealing is named TiBN0.

Observations made by SEM and proposed on a previous paper [31] show recovering and almost homogenous coatings presenting, moreover, more and more visible defects due to the original presence of the powder.

In order to study the ceramic crystallization, XRD was performed on the whole sample series. The corresponding patterns are proposed in Figure 11.

Only regarding peaks corresponding to h-BN at 26.7°, 42.3° and 44.4° (2θ), they appear finer with the crystallization promoter ratio increasing. Besides, measured FWHM$_{002}$ and calculated d$_{002}$ and L$_{002}$ values reported in Table 3 demonstrate that most the sample incorporates Li$_3$N in the pre-mixture, most it becomes crystallized. It has to be noticed that all the other signals display on the XRD patterns are attributed to either titanium or (TiN + TiB$_2$) respectively, the substrate and the interface (according to the JCPDS files 087-0633 and 089-3923).

<table>
<thead>
<tr>
<th>Sample</th>
<th>d$_{002}$ (Å)</th>
<th>θ$_{002}$ (°)</th>
<th>FWHM$_{002}$</th>
<th>Lc (nm)</th>
</tr>
</thead>
<tbody>
<tr>
<td>TiBN5</td>
<td>3.33</td>
<td>26.6</td>
<td>0.67</td>
<td>26</td>
</tr>
<tr>
<td>TiBN3</td>
<td>3.41</td>
<td>26.1</td>
<td>0.92</td>
<td>19</td>
</tr>
<tr>
<td>TiBN1</td>
<td>3.55</td>
<td>25.9</td>
<td>1.54</td>
<td>11</td>
</tr>
</tbody>
</table>

Figure 11. XRD patterns recorded on samples TiBN0 (black), TiBN1 (red), TiBN3 (blue) and TiBN5 (magenta).
In summary, we demonstrate here that it is possible to get crystallized h-BN coating on titanium at only 1200 °C for a total treatment duration of a few minutes. Increasing the IR irradiation time could still increase crystallization but in that case, the thermal conduction occurring from the coating to the substrate will modify the titanium structure (phase transition: 980 °C), which is not allowed. To the best of our knowledge this is the best compromise between the crystallization rate and the substrate preservation. Further studies [31] have shown that coatings prepared with an additivated precursor and treated under RTA present very interesting mechanical and adhesion properties for tribological applications.

3.4. BNNS Preparation

If the availability of thick h-BN coatings on metallic substrate is very interesting for mechanical and tribological applications, recent works, essentially based on graphene heads towards 2D nanostructures preparation. In this new context, we decided to take advantage of the good results obtained on the PBN additivation to favor the synthesis of well-crystallized BNNSs [103].

Hence, we simply prepare a bulk sample using PBN additivated with Li3N (5wt. %) annealed, under N2, at 1400 °C (1 °C/min) for 1 h after a 1-hour pre-stabilization at 200 °C (on a hot plate). Here again, high crystallization of the obtained white powder is clearly proved by Raman spectroscopy and XRD. Raman scattering spectrum, reported on Figure 12, is typical of h-BN with a unique signal at 1367 cm−1 displaying a weak FWHM value (17 cm−1).

![Figure 12. Raman spectrum recorded on bulk LiBN05.](image)

Regarding , the XRD pattern (Figure 13) in comparison with commercial h-BN (HENZE BNP GmbH support) is also characteristic of highly crystallized h-BN with thin and well defined diffraction peaks at 2θ = 26.9°, 41.8°, 44°, 55.2°, 75.9° and 82.1° corresponding to (002), (100), (101), (004), (110) and (112) crystallographic planes, respectively according to the JCPDS file 009-0012. However, we can note the absence of the (102) crystallographic plan expected at 50.3° (2θ). In addition, taking into account the fact that calculated relative intensity of each peak (Table 4) are consistent with theoretical ones only for the (002) and (004) signals, suggest the synthesis of ceramic with 2D dimension. Two supplementary peaks can also be detected at 2θ = 42.6° and 45.6° and attributed to rhombohedra BN (r-BN) (JCPDS file 045-1171). Structure of r-BN is similar to that of h-BN with a stacking of alternative atomic layers ABC-ABC instead of AB-AB for h-BN [16,104].

<table>
<thead>
<tr>
<th>Sample</th>
<th>d 002 (Å)</th>
<th>θ 002 (°)</th>
<th>FWHM (002)</th>
<th>Lc (nm)</th>
</tr>
</thead>
<tbody>
<tr>
<td>TiBN1</td>
<td>3.55</td>
<td>25.9</td>
<td>1.54</td>
<td>11</td>
</tr>
<tr>
<td>TiBN3</td>
<td>3.41</td>
<td>26.1</td>
<td>0.92</td>
<td>19</td>
</tr>
<tr>
<td>TiBN5</td>
<td>3.35</td>
<td>26.4</td>
<td>1.09</td>
<td>23</td>
</tr>
</tbody>
</table>

Table 3. Main XRD parameters of samples TiBN1, TiBN3 and TiBN5.
These sheets are used to get h-BN epitaxial graphene van der Waals heterostructures by deposing a drop of a solution of h-BN layers on ethanol on an epitaxial graphene, demonstrating the interest of getting well-crystallized powders easily exfoliated to get 4-, 3-, 2-, layers and even monolayers [103].

In order to confirm the sample microstructure, the raw powder is dispersed in ethanol under ultrasound, for a chemical exfoliation step, then observed by TEM. Figure 14 presents representative micrographs obtained on exfoliated BN. Figure 14b displays diffraction contrasts that are characteristics of the perfect sample crystallization. Misorientations between h-BN layers may explain those patterns as shown on the image at higher resolution (Figure 14a) where perfectly crystallized sheets are stacked on each other in a disorderly manner. This is also revealed by multiple spots in the corresponding Selected Area Electron Diffraction (SAED) patterns obtained on different sample areas (Figure 14a inset), and exhibiting several sets of six hexagonal spots rotated with various angles, demonstrating the achievement of h-BN single crystals stacked respectively in a AA’ structure along the c-direction or in a more complex turbostratic structure. This relative rotation may be attributed to the stain induced by the rolled structure and the folding of sheets on themselves. The High Resolution Transmission Electron Microscopy (HRTEM) performed on a fine zone of one sheet shows the perfect atomic in-plane arrangement characteristic from the hexagonal lattice (Figure 14c). Several dark lines with interatomic distance measured at 3.33 Å are experimentally measured on the edges of the sheet, giving its number of layers. The diffraction pattern associated with this sheet clearly exhibits hexagonal bright dots, representative of single crystal.

It is shown that, by adding a crystallization promoter into the preceramic polymer, it is possible to get well-crystallized powders easily exfoliated to get 4-, 3-, 2-, layers and even monolayers [103]. These sheets are used to get h-BN epitaxial graphene van der Waals heterostructures by depositing a drop of a solution of h-BN layers on ethanol on an epitaxial graphene, demonstrating the interest of these starting materials [105]. However, in any case, the BNNSs size remains critical to consider applications as graphene substrate or to modify the electronic properties. In that way, alternative ways have to be found in order to increase the domains’ size and preserving the high crystallization level.

**Table 4.** Main XRD parameters of commercial h-BN and LiBN05.

<table>
<thead>
<tr>
<th>Signal Intensity</th>
<th>(200)</th>
<th>(100)</th>
<th>(101)</th>
<th>(102)</th>
<th>(004)</th>
<th>(110)</th>
<th>(112)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Theoretical intensity</td>
<td>100</td>
<td>15</td>
<td>6</td>
<td>15</td>
<td>6</td>
<td>5</td>
<td>5</td>
</tr>
<tr>
<td>Calculated intensity</td>
<td>100</td>
<td>3.7</td>
<td>2.5</td>
<td>0</td>
<td>5</td>
<td>2.8</td>
<td>2</td>
</tr>
</tbody>
</table>

**Figure 13.** XRD patterns recorded on commercial h-BN (black) and on LiBN05 (red).
4. Third Strategy: Combining PDCs with SPS

Once we have been able to get pure and well-crystallized h-BN nanosheets using a crystallization promoter, the next step is to increase the lateral size of the obtained flakes. This step is of primary importance for the use of h-BN under different configurations: as an insulating substrate for graphene [57,58] or for creating new van der Waals heterostructures [61,106–108]. Our strategy is to combine the advantages of the PDCs route to those of the Spark Plasma Sintering (SPS) (Figure 15) process in order to synthesize important amount of pure, well-crystallized and large-scale (>10 μm) h-BN flakes, which could be further easily exfoliated into BNNSs.

Figure 15. Scheme of the Spark Plasma Sintering.
To perform the experiment, liquid PBN, mixed with Li$_3$N micro powder (5 wt. %) is preceramized at 650 °C. The latter amorphous BN powder is then sintered by SPS in order to favor crystallization and increase crystals size. After sintering, we obtained a very dense white pellet of 2 cm in diameter.

### 4.1. Characterization of the Bulk h-BN Pellet

The white pellet (Figure 16) is first investigated by X-ray photoelectron spectroscopy before and after an Ar$^+$ sputtering of the surface. Results obtained before abrasion of the surface gives an elemental B/N ratio of 0.97, very close to the one of stoichiometric BN and consistent with reported XPS data for BN [109]. Carbon and oxygen contaminants are also observed attributed to extrinsic pollution as they disappear on the second analysis performed after 1 µm abrasion (4 keV Ar$^+$ sputtering).

![Image of the 2 cm-diameter white pellet.](image1.png)

**Figure 16.** Image of the 2 cm-diameter white pellet.

SEM performed on the same sample shows a homogeneous stacking of h-BN flakes (up to 30 µm) preferentially oriented perpendicularly to the pellet surface i.e. aligned in the compression direction and the external current (Figure 17a). A detailed flake is also presented on Figure 17b to prove the large flake size.

![SEM performed on the bulk pellet: (a) Stacking of h-BN flakes; (b) Representative single flake.](image2.png)

**Figure 17.** SEM performed on the bulk pellet: (a) Stacking of h-BN flakes; (b) Representative single flake.

The preferential orientation of the flakes is confirmed by X-ray diffraction recorded on both pellet surface and pellet cross-section (Figure 18). Even if both patterns exhibit thin, intense and well-separated peaks assigned to expected crystallographic planes from an h-BN crystal (JCPDS file 009-0012), the comparison of both diffractograms clearly shows a preferential orientation of the h-BN crystallites along the $a$-axis (characteristic of the covalent B-N bond), that is parallel to the applied load.
The good crystallinity of the sample deduced from the XRD patterns is also observed on the Raman spectrum (Figure 19). The well-defined symmetric single peak recorded at 1366 cm$^{-1}$, which is characteristic of the E$_{2g}$ vibration mode of h-BN crystal [33], presents a FWHM value of 7.7 cm$^{-1}$ comparable to the best values reported for the h-BN single crystals obtained by HPHT [77,78,89,110] and strongly improved compared to 17 cm$^{-1}$ for PDCs BNNSs presented above. This last result evidences a very low defect density combined with a very large crystallite size.

In summary, by coupling the PDCs method described above with SPS process, we can synthesize large micrometers-crystallized domains (up to 30 µm) of pure h-BN growing in the sintering load direction. From this sample, we have then prepared Boron Nitride Nano Sheets (BNNSs) by physical (tape) or chemical (in ethanol, ultrasonication: 1 min at 25 W, Hielscher UP400S and centrifugation) exfoliation.

4.2. Characterization of Single Crystal Flakes

Flakes can be exfoliated by the tape method then deposited onto a Si substrate, covered by 80 nm SiO$_2$ oxide layer. An optical examination reveals 10 to 300 nm (Figure 20b) thick pieces with side size.
up to 40 µm (Figure 20c). Raman spectrum recorded on one flake (Figure 20a) displays the single peak of h-BN located at 1366 cm\(^{-1}\) with a 7.5 cm\(^{-1}\) FWHM, reflecting once more the excellent crystallinity of the flakes.

![Figure 20](image)

**Figure 20.** (a) Raman spectrum recorded on one h-BN single crystal flake; (b) AFM image of 300 nm-thick flake; (c) Optical image of a side-size flake up to 50 µm.

TEM observations of 5–30 µm flakes confirmed the high crystalline quality of samples (Figure 21). Actually, diffraction contrast (dark areas correspond to crystallized zones of the flake in Bragg’s position) (Figure 21a, b) visible on a representative flake (Figure 21a) attests the crystallinity of the final ceramic. Figure 21c represents a TEM image of the edge of the flake showing the perfect staking of BNNSs composing the flake.

![Figure 21](image)

**Figure 21.** TEM observations performed on 5–30 µm flakes: (a) and (b) BF-TEM images showing diffraction contrast; (c) TEM image of the edge of the flake proving the staking of BNNSs composing the flake.

### 4.3. Characterisation of the BNNS

The size distribution of the crystals before chemical exfoliation, and of the BNNSs after chemical exfoliation, has been respectively studied from SEM and optical images [76]. After exfoliation, BNNSs thickness slows down to several nanometers and the BNNSs size (10 to 15 µm vs. 30 µm for crystals)
is lowered. The surface roughness of h-BN deposited onto SiO$_2$ substrate has then been measured by AFM and the RMS (Root Mean Square) value has been determined to 0.7 nm, similar to the one measured for standard silica. This means that our samples would be flat enough to be used as graphene substrates or to produce Van der Waals heterostructures. A droplet of the chemical solution was then simply deposited onto a 300 mesh holey carbon copper grid in order to perform TEM observations. Figure 22a proposes a typical TEM image obtained on 5–10 µm size BNNSs. Another image (Figure 22b) still performed on a typical sample shows how the BNNSs delaminate from each to other leading to a large amount of nanolayers. Finer observation by HRTEM allows to get image of a 4- layers BNNS, the thickness being determined counting the dark lines. SAED pattern (Figure 22c, inset), obtained from the high resolution image (Figure 22), shows six bright spots hexagonally distributed, demonstrating the achievement of well crystallised h-BN. This SAED pattern can be interpreted as the AA’ atomic stacking along the c-direction.

Finally, EELS spectra are recorded on thin BNNSs and show only boron and nitrogen K-edges without any trace of lithium, carbon or oxygen, corroborating previous XPS results on the excellent purity of samples.

To conclude, by combining PDCs route with SPS method, we associated the synthesis of high purity ceramic to the high crystallinity sintering. We obtained very pure and well crystallized large flakes (up to 30 µm) orientated along the compressed direction. By exfoliating these flakes, we can obtain a large amount of self-standing h-BN few-layers whose quality may open new perspectives for many applications as graphene substrate or to produce van der Waals heterostructures.
5. Materials and Methods

5.1. Borazine and PBN Syntheses

Pure borazine \( (B_3N_3H_6) \) is obtained from a reaction between ammonium sulfate \([(NH_4)_2SO_4, 99\% \text{ purity, Aldrich}] \) and sodium borohydride (NaBH\(_4\), 98\% purity, Aldrich) in tetruglyme heated to 120 °C according to a procedure described elsewhere \([111]\). After purification by distillation, borazine is then heated at 50 °C inside a pressure-sealed system under argon for 5 days, generating a colorless polyborazilene (PBN). PBN is kept below 4 °C to exclude further polymer reticulation. Elemental analysis performed on the used PBN gives the general chemical formula \( (B_{3.0}N_{3.8}H_{4.0})_n \). When necessary, lithium nitride (Li\(_3\)N, Aldrich) micro powders in different percentage (more often: 5wt. %) is added to PBN, and the mixture is kept with stirring in a Schlenk tube under argon for 10 min. The mixture is then used as such or after a preceramisation process hold into an alumina crucible under \( \text{N}_2 \), at 650 °C (1 °C/min) and kept at this final temperature for 1 h.

5.2. Characterization Tools

X-ray PhotoSpectroscopy (XPS) data are recorded using a PHI Quantera SXM instrument (Physical Electronics, Chanhassen, MN, USA) equipped with a 180 hemispherical electron energy analyzer and a monochromatized Al K\( \alpha \) (1486.6 eV) source operated at 15 kV and 4 mA. ThermoGravimetric Analyses (TGA) are performed with a TGA/SDTA 851 (Mettler Toledo, Colombus, OH, US), under 50mL/min N\(_2\) from 25 to 1400 °C in an alumina crucible (at a rate of 20 °C/min). The Raman scattering measurements are collected either with an XY Dilor triple spectrometer followed by a nitrogen-cooled CCD (charge-coupled device) multichannel detector or using a Horiba Jobin-Yvon ARAMIS spectrometer (Horiba, Kyoto, Japan) equipped with a 1800 lines/nm grating, using an excitation wavelength of 532 nm and a \( \times 50 \) objective (the main Raman band of the silica peak is located at 520.1 cm\(^{-1}\)). X-ray Diffraction (XRD) analyses (Phillips PW 1830/40 (Phillips, Amsterdam, Netherlands)) with a Cu-K\( \alpha \) radiation source are carried out at room temperature. Transmission Electronic Microscopy (TEM) observation is performed using a JEOL 2100F (Jeol, Tokyo, Japan) and 2010F microscopes operating at 200 kV. Electron Energy Lost Spectroscopy (EELS) spectra are recorded using a JEOL JEM-ARM200F Cold FEG (Jeol, Tokyo, Japan), operating at 200 kV. Scanning Electron Microscopy (SEM) is performed with a SUPRA Zeiss (Supra Zeiss, Iena, Germany) at very low accelerating voltage (200 V).

5.3. Specific Apparatus

IR irradiation annealing. Two annealing processes are used in the context of this study. The first employs a halogen lamp with a gold reflector MR16 (OSRAM, XENOPHOT, Munich, Germany) in a gloves box filled with argon. Voltage power was increased (100 °C/min) until the final temperature is reached, and samples are then hold at this temperature for 90 min. In the second process, samples are placed in a Rapid Thermal Annealing (RTA) cold wall chamber furnace (AS-One, ANNEALSYS Montpellier, France). Temperature is monitored via pyrometer placed under the sample’s back face. Samples are rapidly heated to 900 °C, then 6 or 9 irradiation flashes of 5 s with 100% lamp power (with a final temperature estimated around 1350 °C) are delivered in one of two gas atmospheres (argon or nitrogen), allowing the sample to return to 900 °C between flashes.

Spark Plasma Sintering. In a gloves box, the SPS graphite die covered with a papyex\(^\circledast\) is filled with the preceramic powder and then transferred into the SPS chamber (HP D 25, FCT System (FCT Systeme GmbH, Rauenstein, Germany)) in-between the two punches and compressed at room temperature under uniaxial load until 90 MPa. SPS heating (10 ms pulses ON and 5 ms OFF) is then conducted up to 1800 °C keeping the normal load constant. During the 1 h dwell temperature the current is 770 A and the vacuum in the SPS chamber is 0.15 mbar.
6. Conclusions

This review reports several strategies to synthesis highly crystallized hexagonal boron nitride using the Polymer Derived Ceramics (PDCs) route. This route, which is a great alternative in preparing specific ceramic shapes starting from a tailored polymeric precursor, is often associated with a drastic thermal annealing to get a well-crystallized material. Indeed, due to either equipment or substrate limitations, the implementation of a severe conventional thermal treatment is not often possible. In that context, our group develops the original strategies avoiding high temperature processes with the main goal to reach high performances micrometric h-BN coatings deposited on thermal sensitive substrate and self-standing boron nitride nanolayers. First, we have shown that using an annealing under infrared irradiation led to lower the onset crystallization temperature of about 300 °C compared to a conventional thermal treatments. Secondly, we presented a study on the effect of the additivation of pure polyborazilene with lithium nitride as crystallization promoter. In that case, it is proven that additivation of 5 wt. % Li$_3$N allows preparing highly crystallized h-BN from 1200 °C. Finally, the unique combination of the PDCs route with a relevant sintering process by Spark Plasma Sintering leads to an accessible source of single crystals of h-BN available for a further exfoliation. Using one or the other or combining the complementary approaches, may give rise to high performance devices suitable for aeronautic or electronic applications.

Acknowledgments: Authors gratefully acknowledge the ANR for its financial support through the project 14-CE08-0018 «GoBN», the CTµ (Centre Technologique des Microstructures) of the Université Lyon 1 and CLYM (Centre Lyonnais de Microscopie) for access to TEMs.

Author Contributions: All authors contributed to the experiments and discussions presented in this review.

Conflicts of Interest: The authors declare no conflict of interest.

References


82. Vilcarromero, J.; Carreño, M.N.; Pereyra, I. Mechanical properties of boron nitride thin films obtained by RF-PECVD at low temperatures. Thin Solid Films 2000, 373, 273–276. [CrossRef]
91. Shipilo, V.B.; Ignatenko, O.V.; Shempel, N.A.; Azarko, I.I.; Lebedev, S.A. Crystallization of cubic boron nitride in the system Li3N–BN (4–10 wt % Li3N). Inorg. Mater. 2011, 44, 258–262. [CrossRef]


© 2016 by the authors; licensee MDPI, Basel, Switzerland. This article is an open access article distributed under the terms and conditions of the Creative Commons Attribution (CC-BY) license (http://creativecommons.org/licenses/by/4.0/).